

Thermal Stable Perovskite Solar Cells Improved by ZnO/Graphene Oxide as Electron Transfer Layers

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Abstract: ZnO/graphene oxide (GO) nano-particles (NPs) layer was prepared using a facile solution process and employed as an electron conductor to improve the thermal stability of perovskite solar cells. Structural changes during the degradation process in high temperature environment were characterized *via in situ* grazing incidence X-ray diffraction. The optical properties and surface morphologies of the films were characterized. It was observed that smooth and compact structure of ZnO/GO layer works as a protection layer to prevent decomposition of perovskite film which is converted into PbI₂ during the annealing process reaction. The perovskite film grown on ZnO/GO layer exhibited enhanced crystallization, high surface coverage ratio as well as preferred in-plane orientation of the (110) plane.

Key words: GIXRD; ZnO/GO; perovskite; ETL (electron transfer layers)

Efficient solar cells comprising earth-abundant and non-toxic metal-oxide absorbers are very attractive due to the sustainable material usage and potential for cost-effective manufacturing^[1]. In particular, the discovery of hybrid perovskite as a light absorbing component has been a breakthrough. Since the first reports by Miyasaka, *et al*^[2], solar-cell-devices based on hybrid perovskites of CH₃NH₃PbX₃ (X= I, Br, Cl) type have been improved in power conversion efficiencies (PCEs) from 3.8% to 20.8% in only a few years^[3-4].

To fabricate perovskite solar cells, different types of electron transfer layers (ETLs) and hole transfer layers (HTLs) have been employed. Regarding the ETL materials, more stable metal oxides, such as titanium dioxide (TiO₂), zinc oxide (ZnO), and tin oxide (SnO₂) have been developed for perovskite solar cells^[5]. Among these metal oxides, TiO₂-nanoparticles (NPs) have been commonly used as the ETL to provide an efficient charge collection. To prepare a TiO₂ mesoporous layer, a sintering process with high temperature (≈500°C) is required^[6]. This temperature is too high for fabrication. What's more, the lack of thermal stability of perovskite solar cells is hindering the progress of this technology towards adoption in the consumer market. ZnO NPs are, therefore, a promising candidate to replace TiO₂ as the ETL layer in perovskite solar cells.

However, only a few works have reported perovskite solar cells based on ZnO NPs. The devices on ZnO NPs show a maximum PCE of close to 15.7%^[4], which is lower than those on TiO₂ NPs. In addition, a few works have demonstrated the instability of perovskite materials on top of ZnO NPs after annealing at a relative high temperature, especially using a one-step process^[7]. What's more, other researchers have demonstrated that the annealing of the perovskite at lower temperature results in poor device performance^[8]. Recently, a monolayer of graphene with a honeycomb lattice has attracted considerable attention for use in photovoltaic applications due to the fact that they work as a fast electron funnel. Wang, *et al*^[9] demonstrated that the hybrid nanostructure of graphene and TiO₂ NPs can improve performance of a perovskite solar cell up to 15.6%.

In this work, we synthesized smooth ZnO/GO film and employ it as an ETL in a perovskite solar cell to explore whether CH₃NH₃PbI₃ perovskite material after being deposited on top of the layer could be higher stability after annealing process at 100°C due to the formation of the hybrid structure(ZnO/GO).

1 Experimental

1.1 Materials and devices fabrication

Methylammonium iodide (MAI) was synthesized

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according to the literature^[10]. GO was obtained from a modified Hummer's method with flake expandable graphite used as the original material according to a previously reported protocol^[11]. To prepare the perovskite precursor solution, MAI (99%, Materwin Technology) and lead iodide (PbI_2 , 99.999%, Alfa) powder were mixed in anhydrous N,N-dimethylformamide (DMF, 99.9%, Aldrich) with a molar ratio of 3:1. The perovskite precursor solution was stirred at 60°C for 6 h and filtered through PTFE filters (0.45 μm) prior to use. The glass substrate coated with patterned indium tin oxide (ITO) with a sheet resistance of 10 Ω/\square was cleaned with a detergent, ultrasonicated in acetone and ethanol, and then blow dried with nitrogen. Subsequently, the substrates were treated with ultraviolet ozone plasma for 15 min. 50 nm thick layer of ZnO/GO was deposited on the ITO substrates by the cathodic electrophoretic deposition (EPD) technique that can be found described elsewhere^[12-13]. 40wt% $\text{CH}_3\text{NH}_3\text{PbI}_3$ precursor solution was spin-coated at 3500 r/min for 60 s. After lying in a petri dish at room temperature for 15 min, the perovskite films were annealed on a hot plate at 100°C for 30 min, allowing the color of the films to turn to black. Subsequently, The spin coating formulation was prepared by dissolving 72.3 mg 2,2',7,7'-Tetrakis(N,N-p-dimethoxyphenylamino)-9,9'-spirobifluorene (spiro-MeOTAD), purchased from Alfa, 30 μL 4-tert-butylpyridine and 20 mL of a stock solution of 520 mg/mL lithium bis (trifluoromethylsulphonyl) imide in acetonitrile in 1 mL chlorobenzene. Finally, 90-nm-thick gold electrodes were deposited on top of the devices by evaporation at 10^{-4} mbar.

1.2 Characterization

The microstructure of each sample was characterized by X-ray diffraction (XRD) and *in situ* grazing incidence X-ray diffraction (GIXRD) at beamline BL14B1 beamline of the Shanghai Synchrotron Radiation Facility (SSRF) using X-rays at a wavelength of 0.124 nm. Two-dimensional GIXRD(2D-GIXRD) images were acquired with a MarCCD, mounted vertically, at a distance of 364 mm from the sample, with a grazing angle of incidence of 2° and an exposure time of 20 s. The 2D GIXRD patterns were analyzed using the FIT2D software and displayed in scattering vector q coordinates, where $q=4\pi\sin\theta/\lambda$, θ is half of the diffraction angle, and λ is the X-ray wavelength. Transmittance spectra were recorded via a UV-Vis spectrophotometer (UV3010). The surface morphologies of the samples were observed by atomic force microscopy (AFM) (Nanoscope IIIa). The surface morphology of films was observed by scanning electron microscope (SEM, LEO1530). Device characteristics and PCE were measured in a glovebox under a Newport 94023A solar simulator equipped with a 300 W Xenon lamp, and an air

mass(AM) 1.5G filter was used to generate a simulated AM 1.5G solar spectrum irradiation source.

2 Results and discussion

2.1 Surface structure of ZnO/GO NPs

To study the surface of the ZnO film, X-ray diffraction (XRD) is employed. Fig. 1(a) and 1(b) show XRD pattern of the GO and ZnO/GO films, where the diffraction peaks of the ZnO/GO film are related to the crystalline ZnO (JCPDS 36-1451). In Fig. 1(a), peaks of the GO layer were found at $2\theta=25.81^\circ$, 43.51° and peaks at 25.81° , 43.51° existed in Fig. 1(b) support the successful formation of the hybrid structure.

2.2 Properties of ZnO/GO NPs

To probe the effect of ZnO/GO film as an ETL, its surface morphology and optical properties were studied. Ultraviolet-visible (UV-Vis) spectroscopy (Fig. 2(a)) of ZnO/GO film as compared to ZnO film shows an auxiliary enhanced absorption edge to longer wavelengths (a red-shift of ≈ 18 nm) because of the size effect. As shown in Fig. 2(b), ZnO/GO NPs(0.85 nm) becomes larger than ZnO(0.26 nm) due to the hybrid structure. Fig. 2(c) depicts the top-view SEM image of this layer with a high coverage and uniformity. The surface roughness of the

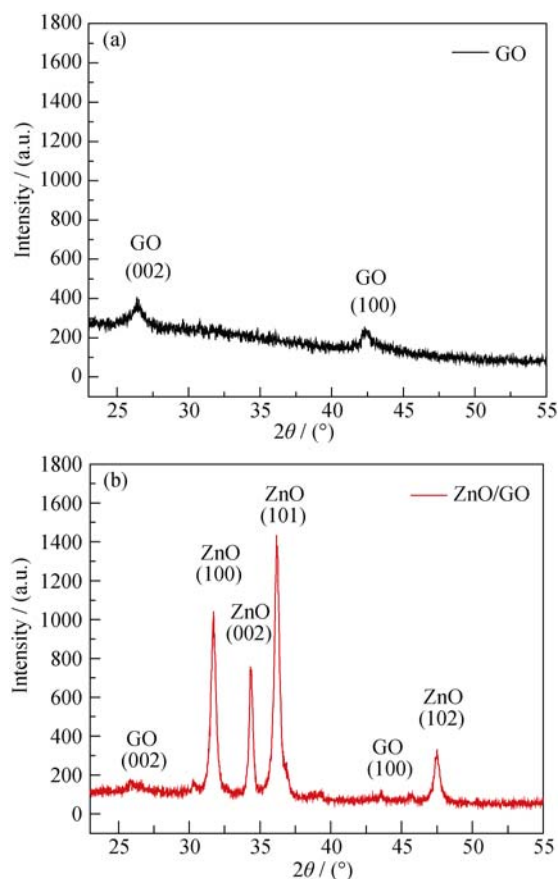


Fig. 1 XRD patterns of GO and ZnO/GO films

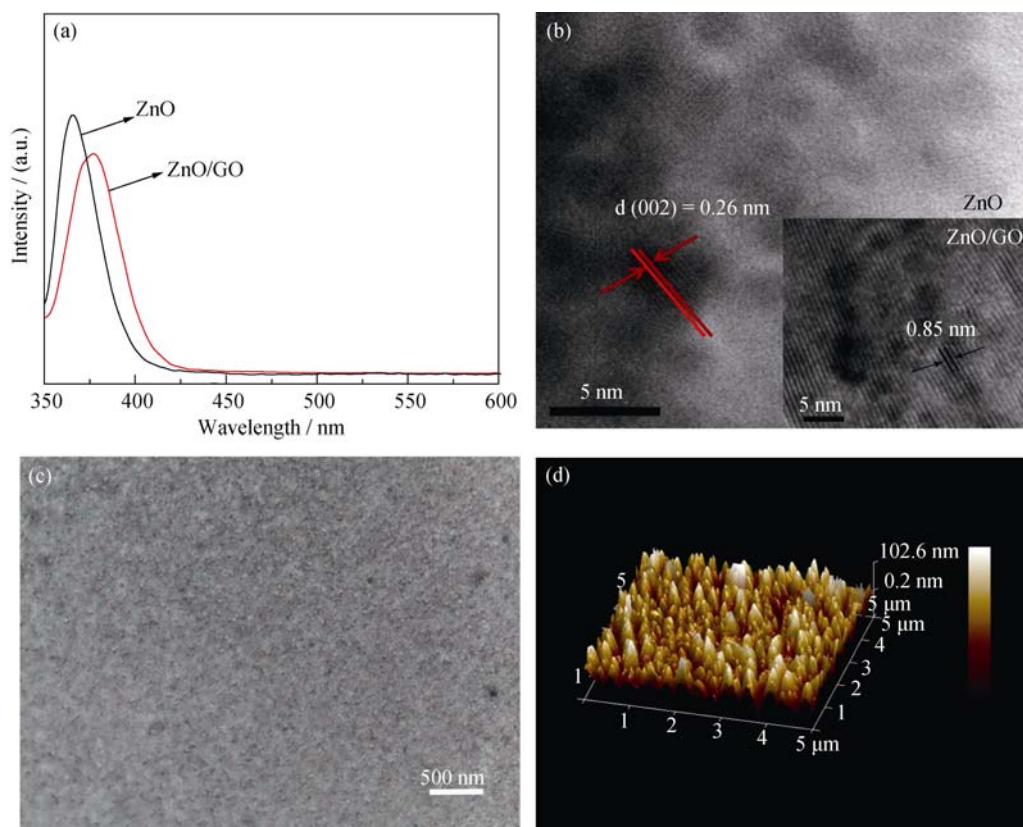


Fig. 2 (a) UV-Vis absorption and (b) TEM images of ZnO/GO films and ZnO film. (c) Top-view SEM image and (d) AFM image of ZnO/GO films

films were further monitored using high-resolution atomic force microscopy (AFM), as shown in Fig. 2(d). The size of the AFM images is $5 \mu\text{m} \times 5 \mu\text{m}$. The root mean square (RMS) roughnesses of $\text{CH}_3\text{NH}_3\text{PbI}_3$ film deposited on ZnO/GO layer was approximately 28.9 nm , indicating that it is suitable for the replacement of ZnO layer as the ETL.

2.3 GIXRD studies

Snapshots of the *in situ* GIXRD experiments at various points in time are shown in Fig. 3. All of the GIXRD patterns exhibited a relatively strong scattering background from the amorphous glass substrate in the range of $q=10\text{--}25 \text{ nm}^{-1}$, where q is the scattering vector ($q=4\pi\sin(\theta)/\lambda$). After calibration, key features of the perovskite diffraction pattern could be observed at $q \approx 10.04$, 19.74 and 22.21 nm^{-1} . These are consistent with reflection from the (110), (220) and (310) lattice planes, respectively^[14].

Fig. 3(a) is the diffraction pattern of the $\text{CH}_3\text{NH}_3\text{PbI}_3$ film deposited on ZnO/GO after heating at 100°C in air for 2 min, which reveals that the film is polycrystalline with preferred in-plane orientation of the (110) plane. The strong and sharp (110) peaks imply that the films possess good crystallization and large crystal size. When the film was heated to 100°C for 15 min (Fig. 3(b)), a new feature at $q \approx 9 \text{ nm}^{-1}$ appeared, which is consistent with reflection

from the (001) planes of PbI_2 (PDF#07-0235), but the ring is not so clear, indicating that just a little amount of $\text{CH}_3\text{NH}_3\text{PbI}_3$ decomposed after 20 min. Yang^[7] studied the $\text{CH}_3\text{NH}_3\text{PbI}_3$ film deposited on ZnO, suggesting that after 13 min of heating at 100°C , the perovskite decomposes into PbI_2 in a single step. Herein, it can be concluded perovskite structure on the ZnO/GO showed a higher stability than it on ZnO. According to Fig. 3(c), it can be found that, after 30 min, the perovskite (110) feature still exist clearly. These data show that after 15 min of heating at 100°C , only small part of $\text{CH}_3\text{NH}_3\text{PbI}_3$ decomposes into PbI_2 , consistent with the result we indicated above.

2.4 Performance of solar cell

Table 1 summarizes the photovoltaic parameters of devices measured under AM 1.5G solar illumination at 100 mW/cm^2 . As presented from the data, the common TiO_2 -based device results in an efficiency of 10.24%. Regarding to the devices employing ZnO as an ETL, efficiency of 9.08% was obtained. When an ZnO/GO layer is introduced into the solar cell, a PCE of 9.31% is obtained, corresponding to an open circuit voltage (V_{oc}) of 1.00 V, a short circuit current density (J_{sc}) of 18.30 mA/cm^2 , and a fill factor (FF) of 0.51. Therefore, ZnO/GO NPs layer is suitable for use in perovskite solar cells.

In order to study the role of ZnO/GO NPs in the device

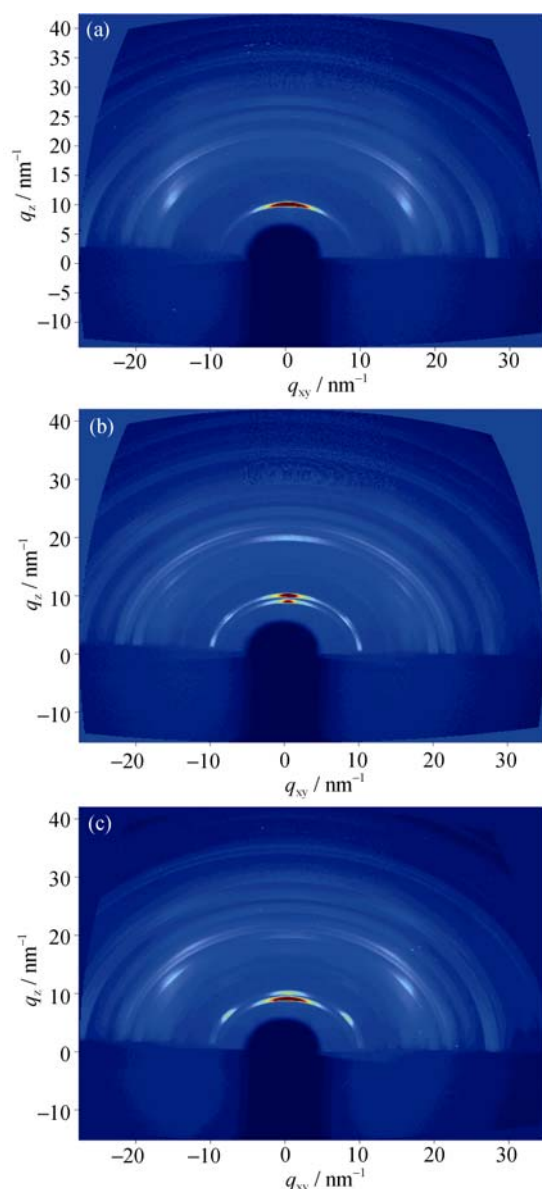


Fig. 3 2D GIXRD patterns of ITO/(ZnO/GO)/CH₃NH₃PbI₃ film after heating at 100°C in air for 2 min (a), 15 min (b), and 30 min (c)

Table 1 Photovoltaic parameters of solar cells with different ETL

ETL	$J_{SC}/(\text{mA}\cdot\text{cm}^{-2})$	V_{oc}/V	FF	$\eta/\%$
TiO ₂	17.06	0.79	0.75	10.24
ZnO	13.71	0.92	0.72	9.08
ZnO/GO	18.30	1.00	0.51	9.31

structure, we have designed a stability test using two samples based on ZnO NPs and ZnO/GO NPs as ETL sealed by UV-epoxy. As demonstrated in Fig. 4, the PCE of the perovskite solar cell on ZnO/GO NPs drops only ~5% after 15 d, which is much more stable than the ZnO one (~80% drop). This experiment supports the importance of GO in order to reduce the reaction between MAPbI₃ and ZnO NPs.

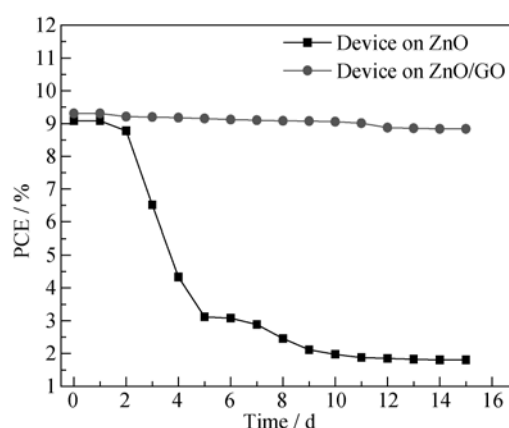


Fig. 4 Stability of the devices based on ZnO NPs and ZnO/GO NPs in an ambient environment after encapsulation using UV-epoxy

3 Conclusion

In order to tackle the problem of heat-induced degradation, we have successfully demonstrated a smooth and compact structure of ZnO/GO NPs according to the XRD result and employ it as an ETL in the perovskite solar cell. Perovskite solar cell with the new hybrid structure has a relative high efficiency of 9.31%. Using this hybrid structure, MAPbI₃ perovskite material demonstrates much improved stability through *in situ* grazing incidence X-ray diffraction even with the annealing process at 100°C. The high quality of the ZnO/GO NPs and good opto-electrical, surface properties make it a candidate of photoelectric materials for the applications in the future.

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ZnO/GO 纳米材料基热稳定钙钛矿太阳能电池

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摘 要: 为了使钙钛矿太阳能电池在高温退火后能够保持稳定, 本研究通过电化学方法制备出氧化锌/氧化石墨烯纳米粒子, 并将其运用到钙钛矿太阳能电池中作为电子传输层使用。通过原位掠入射 X 射线衍射(GIXRD)、X 射线衍射(XRD)、扫描电子显微镜(SEM)和紫外-可见吸收光谱(UV-Vis)等方法对沉积在氧化锌和氧化锌/氧化石墨烯纳米材料上面的甲胺铅碘的结构、形貌以及电池性能变化进行分析测试。结果表明: 氧化锌/氧化石墨烯对于甲胺铅碘有保护作用, 沉积在氧化锌/氧化石墨烯上面的甲胺铅碘薄膜稳定性更高, 电池性能更加稳定, 为将来大面积应用提供了一定的指导。

关 键 词: 掠入射 X 射线衍射; 氧化锌/氧化石墨烯; 钙钛矿; 电子传输层

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